

Construction of bilayer PdSe₂ on epitaxial graphene

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ABSTRACT

Two-dimensional (2D) materials have received significant attention due to their unique physical properties and potential applications in electronics and optoelectronics. Recent studies have demonstrated that exfoliated PdSe₂, a layered transition metal dichalcogenide (TMD), exhibits ambipolar field-effect transistor (FET) behavior with notable performance and good air stability, and thus serves as an emerging candidate for 2D electronics. Here, we report the growth of bilayer PdSe₂ on a graphene-SiC(0001) substrate by molecular beam epitaxy (MBE). A bandgap of 1.15 ± 0.07 eV was revealed by scanning tunneling spectroscopy (STS). Moreover, a bandgap shift of 0.2 eV was observed in PdSe₂ layers grown on monolayer graphene as compared to those grown on bilayer graphene. The realization of nanoscale electronic junctions with atomically sharp boundaries in 2D PdSe₂ implies the possibility of tuning its electronic or optoelectronic properties. In addition, on top of the PdSe₂ bilayers, PdSe₂ nanoribbons and stacks of nanoribbons with a fixed orientation have been fabricated. The bottom-up fabrication of low-dimensional PdSe₂ structures is expected to enable substantial exploration of its potential applications.

1 Introduction

Since the discovery of graphene, investigations into two-dimensional (2D) atomic crystal materials have advanced rapidly [1–3]. Among all the 2D materials fabricated and studied so far, layered transition metal dichalcogenides (TMDs) have emerged as an important class of 2D materials with fascinating physical properties and potential applications [4, 5] due to their sizable

bandgaps and strong spin–orbit and spin–valley coupling effects [6, 7]. Interesting properties emerged when TMD bulk crystals were thinned down to the 2D limit. For example, indirect-to-direct bandgap transitions occurred when bulk MoSe₂ or WSe₂ was thinned down to single layers [8, 9], and a large exciton binding energy of 0.55 eV has been observed in monolayer MoSe₂ [10]. Single layer PtSe₂ exhibits semiconducting properties [11]. Therefore, developing

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experimental techniques to fabricate 2D materials is important.

PdSe₂ is a type of layered TMD known for its unique crystal structure and remarkable layer-dependent electronic structure. In contrast to the well-studied 1T, 2H, and 1T' structures of 2D TMDs [4, 12], PdSe₂ has a puckered pentagonal structure with an orthorhombic lattice [13], which leads to novel properties such as the anisotropic behavior in field-effect transistors (FETs) [14, 15]. 2D materials with puckered pentagonal structures, such as penta-graphene [16] and penta-SnX₂ (X = S, Se, or Te) [17, 18], have been theoretically predicted to have unusual physical properties but remain unexplored experimentally. Under high pressure, bulk PdSe₂ undergoes a structural transition and shows superconductivity [19]. Furthermore, first-principles calculations predict a semiconducting behavior in PdSe₂ with a thickness-dependent bandgap from 0.03 eV in the bulk to 1.43 eV in monolayers [20], which has recently been confirmed by optical absorption spectroscopy [15]. Moreover, FETs based on few-layer PdSe₂ display intrinsic ambipolar characteristics with a high carrier mobility of 158 or 216 cm²·V⁻¹·s⁻¹ and high on/off ratio [14, 15]. In addition, PdSe₂ is stable in air [15]. Its unique pentagonal structure and notable FET performance with good atmospheric stability make PdSe₂ intriguing for applications in electronic and photoelectric devices. Nevertheless, to our knowledge, PdSe₂ thin layers have mainly been fabricated by mechanical exfoliation from the bulk crystal [14, 15, 21]. Epitaxial growth of atomically thin PdSe₂ layers or PdSe₂-based nanostructures has not been realized by either chemical vapor deposition (CVD) or molecular beam epitaxy (MBE). Meanwhile, nanoribbons of 2D materials, especially TMDs, have been theoretically predicted to show intriguing properties, such as magnetic properties [22], strong excitonic correlation effects [23], sizable valley pump effects [24] and high-performance thermoelectric effects [25]. However, bottom-up fabrication of TMD nanoribbons remains challenging and only limited successes have been achieved [26, 27].

In the present work, by using epitaxial graphene on SiC(0001) as a substrate, we report the fabrication of bilayer PdSe₂ based on MBE. The structural and electronic properties of the PdSe₂ layers are investigated

by scanning tunneling microscopy (STM) and scanning tunneling spectroscopy (STS) combined with first-principles calculations. The bandgap of PdSe₂ layers and the band modulation effect by the substrate have been investigated by STS measurements. Moreover, PdSe₂ nanoribbons are also observed to grow on top of the 2D layers.

2 Results and discussion

The atomic structure of bulk PdSe₂ is shown in Fig. 1(a). Bulk PdSe₂ crystallizes in an orthorhombic structure (space group *Pbca*) with a unit cell of $a = 5.7457$ Å, $b = 5.8679$ Å, and $c = 7.6976$ Å [13]. The 2D Se–Pd–Se layers are stacked by van der Waals (vdW) interactions and one unit cell (1UC) contains two PdSe₂ layers due to relative displacement of the two adjacent layers in the *b* direction. The atomic structure of monolayer PdSe₂ is shown in Fig. 1(b). Compared to the structures of the widely investigated T- or H-phase TMDs, in which each transition metal atom binds to six chalcogen atoms, each Pd atom in PdSe₂ binds to four Se atoms, forming a unique puckered pentagonal structure.

Figure 1(c) (as well as Fig. S1 in the Electronic Supplementary Material (ESM)) shows an STM topographic image of PdSe₂ layers grown on a graphene/SiC(0001) substrate, with corresponding X-ray photoelectron spectroscopy (XPS) results shown in Fig. S2 in the ESM. The rectangular shape of the 2D islands in the STM image is consistent with the orthorhombic symmetry of PdSe₂. The apparent height of the island is ~7.8 Å (Fig. 1(d)), suggesting that the islands consist of bilayer PdSe₂ instead of monolayer. We have tried to adjust the experimental conditions, e.g., decreasing the dosing of the precursors; however, monolayer PdSe₂ was never found. Density functional theory (DFT) calculations show that the interlayer interaction in PdSe₂ is significantly stronger than that in other vdW stacking layered materials such as graphite and MoS₂ (see Table S1 in the ESM). This may explain the bilayer growth mode. More experiments and calculations are needed for an in-depth understanding. We note that a recent study using scanning transmission electron microscopy shows that, driven by the creation of Se vacancies under electron irradiation, bilayer PdSe₂ will melt into one layer, forming the new Pd₂Se₃ structure

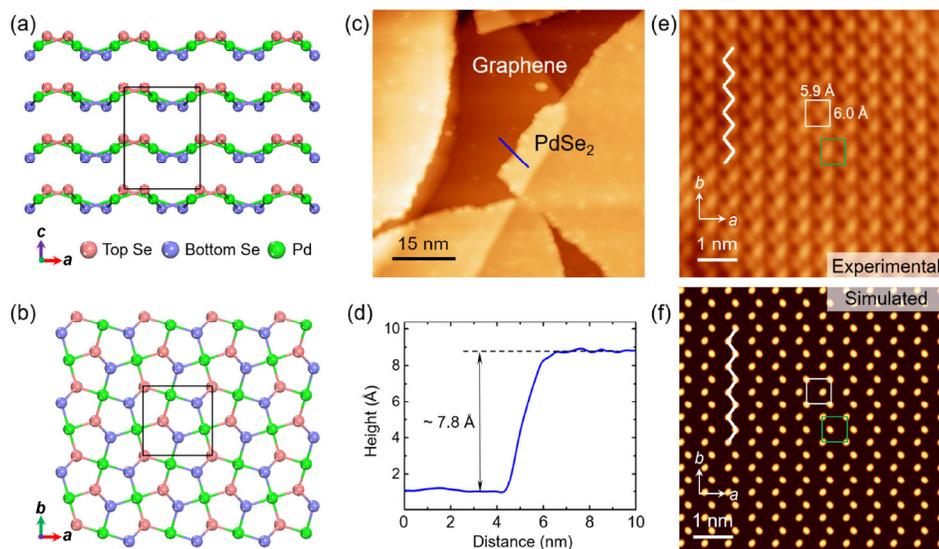


Figure 1 Bilayer PdSe₂ formed on a graphene substrate. (a) Side view of the atomic structure of bulk PdSe₂. The unit cell consists of two PdSe₂ layers, as indicated by the rectangle. (b) Top view of the crystal structure of single layer PdSe₂ showing pentagonal rings. The rectangle indicates the unit cell in a monolayer. (c) An STM topographic image (−3.0 V, 100 pA) of PdSe₂ islands on graphene on SiC(0001). (d) The line profile along the blue line in (c), showing that the apparent height of the island is ~7.8 Å. (e) An atomic-resolution STM image (1.0 V, 100 pA) of the PdSe₂ islands. Two sublattices in the top Se layer are marked with white and green rectangles. (f) Simulated STM image (1.0 V) of bilayer PdSe₂, consistent with the experimental observation in (e). White lines denote zigzag rows in the atomic-resolution image.

[21]. The demonstration of the fabrication technique of bilayer PdSe₂ makes it possible to create and explore more properties of this new 2D phase.

Figure 1(e) shows the atomic-resolution STM image of the PdSe₂ islands, which agrees well with the simulated STM image of bilayer PdSe₂ (Fig. 1(f)). Both constant-current and simulated STM images reveal zigzag rows along the *b* direction (white zigzag line in Figs. 1(e) and 1(f)), which correspond to the topmost plane of Se atoms in the PdSe₂ sandwich-type structure. The surface structure yields two mirror-symmetric rectangle sublattices, as highlighted by white and green rectangles in Figs. 1(e) and 1(f), similar to the puckered surface structure of black phosphorus [28, 29]. The measured lattice constants of the as-fabricated bilayer PdSe₂ are $a = 5.9 \text{ \AA}$ and $b = 6.0 \text{ \AA}$, slightly larger than the bulk values ($a = 5.75 \text{ \AA}$ and $b = 5.87 \text{ \AA}$). Note that Oyedele et al. [15] reported that the optimized bulk lattice constants obtained via optimized Perdew, Burke, and Ernzerhof (optPBE) are $a = 5.85 \text{ \AA}$ and $b = 5.99 \text{ \AA}$, which agree well with our results.

We then investigated the electronic structure of the

fabricated bilayer-PdSe₂ islands through a combination of DFT calculations and STS experiments. Figure 2(a) displays the band structure of the bilayer-PdSe₂ calculated at the PBE level, showing an indirect bandgap of 0.94 eV. As shown in Fig. 2(b), the experimental dI/dV spectrum of the bilayer-PdSe₂ was plotted using a linear scale (black) for the *y*-axis on the left side and a logarithmic scale (green) on the right. The bandgap and positions of the valence band maximum (VBM) and conduction band minimum (CBM) are clearly shown. To better determine the width of the bandgap, we show the statistical distributions of the results from 121 individual tunneling spectra measured from different locations as illustrated in Fig. 2(c). The mean value of the bandgap of the PdSe₂ bilayer is 1.15 eV while the standard deviation (σ) is 0.07 eV, which is a little larger than the calculated result (0.94 eV). Recent work shows the measured bandgap of exfoliated bilayer PdSe₂ by optical absorption spectroscopy is less than 1.0 eV [15]. The difference between our STS result and the optical measurement result might be attributed to the excitonic effects in 2D semiconducting TMDs such as WSe₂ [9] and MoSe₂ [10].

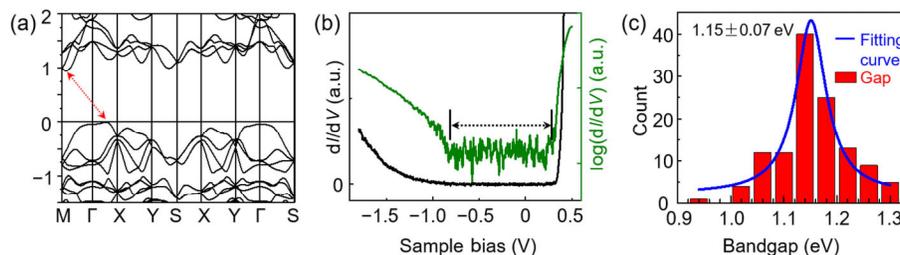


Figure 2 Electronic structure of the bilayer PdSe₂ on a graphene substrate. (a) Calculated band structure of bilayer PdSe₂ using the PBE method. The red arrow indicates the lowest energy transitions between the VBM and CBM. The Fermi energy is set to zero. (b) Scanning tunneling spectrum of bilayer PdSe₂ showing the bandgap. The logarithm of the dI/dV tunneling spectrum is shown in green to accentuate the noise floor within the gapped region. (c) Statistical distribution (from 121 individual dI/dV spectra) of the bandgap measured for bilayer PdSe₂, resulting in a mean bandgap of 1.15 ± 0.07 eV.

Both bilayer graphene (BLG) and monolayer graphene (MLG) can be formed on SiC(0001) surfaces; surface morphology and STS are often used to identify BLG and MLG regions [30]. In our experiments, PdSe₂ layers were found growing continuously across BLG-MLG steps as shown in Fig. 3(a) and the low-magnification image in Fig. S3(a) in the ESM. A high-magnification STM image (Fig. 3(b)) of the area indicated by the black rectangle in Fig. 3(a) confirms the continuity of the PdSe₂ layer.

We carried out STS measurements on the PdSe₂ layer. As shown in Fig. 3(c), a series of tunneling spectra were taken along the dotted black line in Fig. 3(a). The numbers on the spectra refer to their position in the complete set, in which spectra were acquired every 1.25 nm. From the PdSe₂ layer on top of the BLG to that on the MLG area, a downward band bending can be clearly resolved, as indicated by the dashed black line in Fig. 3(c). This band bending starts at spectrum #15, the first dot in PdSe₂ on MLG/SiC, and finally tends towards stability with a shift of ~ 0.2 eV after 5 nm. Two individual spectra of PdSe₂ on BLG and MLG from another experiment are shown in Fig. 3(d). The dI/dV curves of PdSe₂ on BLG and MLG are very similar except for a clear shift of 0.2 eV, which is likely due to the substrate doping effect. Typically, the CBM and VBM of PdSe₂ sheets on BLG/SiC are located at 0.31 and -0.84 eV, respectively. However, on MLG/SiC substrate, the CBM and VBM of PdSe₂ sheets moved to 0.12 and -1.06 eV, respectively.

This result is further evidenced by a dI/dV mapping measurement. Figure 3(e) displays the STM topography image of bilayer-PdSe₂ across the BLG-MLG step edge,

showing the apparent height difference. However, the simultaneously acquired dI/dV signal taken at 0.20 V sample bias has a reversed contrast, as shown in Fig. 3(f), owing to the lower local density of states at 0.20 eV for PdSe₂ on the BLG region compared to that on MLG. The dI/dV mapping confirms the shift of the PdSe₂ band structure with an atomically sharp boundary.

Increasing numbers of graphene layers on SiC weaken the charge transfer from the substrate, resulting in varied electronic properties of the as-fabricated bilayer-PdSe₂. PdSe₂ sheets can grow continuously on mono- and bi-layer graphene. Therefore, we have realized nanoscale and atomically sharp electronic junctions in 2D PdSe₂ layers by controlling the number of underlying graphene layers. The in-plane band modulations of PdSe₂ layers make it possible to tune electronic and optoelectronic properties of 2D TMD semiconductors, or even build p-n junctions for potential applications in photovoltaics and electronics.

Besides 2D islands, one-dimensional (1D) PdSe₂ nanostructures form on top of the PdSe₂ islands and the orientations of these nanostructures follow one of the rectangular island's edges as shown in Figs. S3(a) and S4(a) in the ESM, suggesting an epitaxial growth mode. To understand the 1D PdSe₂ nanostructures, we fabricated samples with lower coverages. PdSe₂ nanoribbons with ~ 5 nm widths were observed on the islands as shown in Fig. 4(a). An atomic-resolution image of a nanoribbon is shown in Fig. 4(b), confirming the same surface structure and epitaxial growth as the underlying PdSe₂ islands.

We measured the apparent heights of the nanoribbons

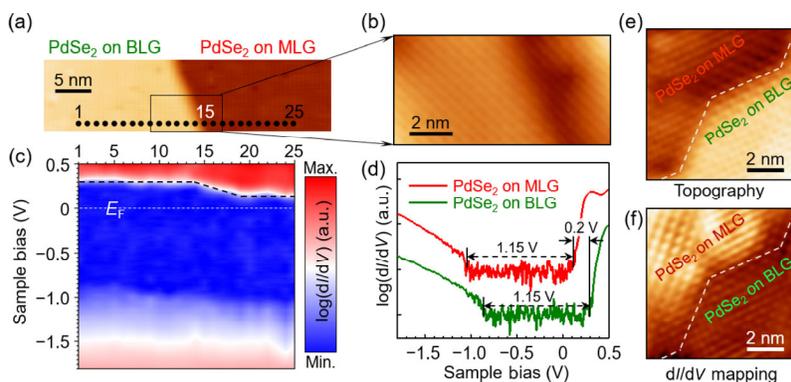


Figure 3 Electronic properties of PdSe₂ bilayers on MLG and BLG on SiC(0001). (a) STM image (2.0 V, 100 pA) showing one PdSe₂ bilayer across the BLG-MLG substrate. (b) High-magnification STM image (0.5 V, 100 pA) of the black rectangle in (a), revealing the continuity of the PdSe₂ layer above the BLG-MLG step edge. (c) dI/dV spectra plotted in a 2D color mapping in logarithmic scale. 25 curves were measured with an interval of 1.25 nm along the path shown in (a). (d) dI/dV spectra of one PdSe₂ island on BLG (green) and MLG (red) show the bandgap shift clearly. The curves are vertically offset for clarity. (e) An STM topographic image (0.2 V, 100 pA) of a PdSe₂ island across BLG-MLG. (f) Corresponding dI/dV mapping image (0.2 V, 100 pA) of (e).

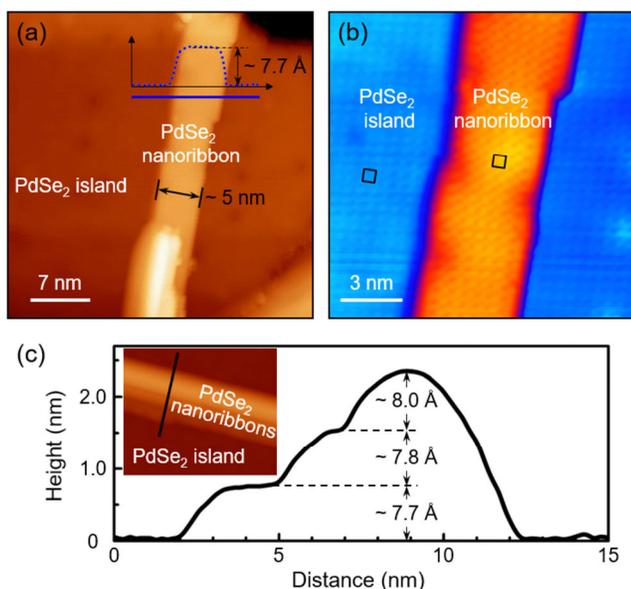


Figure 4 PdSe₂ nanoribbons growing epitaxially on PdSe₂ islands. (a) An STM topographic image (1.0 V, 100 pA) of a bilayer-PdSe₂ nanoribbon on a bilayer-PdSe₂ island. (b) An atomic resolution STM image (1.0 V, 100 pA) of a bilayer-PdSe₂ nanoribbon showing the same surface structure and orientation as the underlying PdSe₂ island. (c) Line profiles across multilayer PdSe₂ nanoribbons, showing the same (~ 7.7 Å) apparent height of each layer.

located on different layers as shown in Figs. 4(a) and 4(c). They have almost identical heights of ~ 7.7 Å, in good agreement with bilayer PdSe₂, indicating that the first bilayer-PdSe₂ nanoribbon grows on top of the bilayer-PdSe₂ 2D island and the second and third bilayer-PdSe₂ nanoribbons grow on the first nanoribbon sequentially. Given higher precursor dosages, the

nanoribbons can stack together to form multilayers. In such cases, the building blocks are always bilayer nanoribbons, as shown in Fig. 4(c). The strict bilayer stacking behavior suggests again the stable nature of the bilayer structure of PdSe₂, which corresponds to one unit cell of the bulk.

As shown in Fig. S4(a) in the ESM, the orientation of the nanoribbon follows the direction of one edge of the island and Fig. S4(b) in the ESM shows that the direction of that edge is the same as the direction of the zigzag rows, which is along the *b* direction as we can see from Figs. 1(e) and 1(f). The anisotropic surface structure of PdSe₂ may lead to faster nucleation of the second PdSe₂ layer in the *b* direction with respect to *a*, and thus result in the formation of 1D nanoribbons. This is in clear contrast to the growth behavior of PdSe₂ on the graphene surface, which has a different symmetry than PdSe₂ and would therefore lead to isotropic growth of the 2D PdSe₂ islands. Since 1D nanoribbons of TMDs are a class of highly desirable materials owing to their predicted unusual properties, the bottom-up fabrication of PdSe₂ nanoribbons gives researchers an opportunity to explore the electronic properties of the TMD nanoribbons family.

3 Conclusions

In summary, we have demonstrated the MBE growth of bilayer PdSe₂ islands on bilayer and monolayer

graphene on SiC(0001). A bandgap of 1.15 ± 0.07 eV was revealed by STS measurement. Moreover, a 0.2 eV bandgap shift was observed in PdSe₂ layers grown on monolayer graphene as compared to those grown on bilayer graphene on SiC. The realization of nanoscale and atomically sharp electronic junctions in PdSe₂ sheets suggests the possibility of tuning the electronic or optoelectronic properties for potential technological applications. In addition, structurally well-defined PdSe₂ nanoribbons have been achieved on PdSe₂ islands and the nanoribbons exhibit stacking growth with a fixed orientation. The bottom-up fabrication of 1D PdSe₂ nanoribbons is expected to enable substantial exploration of 1D TMDs.

4 Methods

4.1 Experimental details

Experiments were carried out in an ultrahigh vacuum STM system, with a base pressure of 2.0×10^{-10} mBar, equipped with standard MBE capabilities for *in-situ* sample preparation. A nitrogen-doped 6H-SiC(0001) wafer (0.1 Ω ·cm) was graphitized by flashing to 1,550 K, leading to a graphene terminated surface [31, 32] as the substrate for the MBE growth of PdSe₂. The quality of the graphene was evaluated by low-energy electron diffraction (LEED) and STM. High-purity Pd (99.95%, Alfa Aesar) and Se (99.999%, Alfa Aesar) sources were simultaneously evaporated from an electron-beam evaporator and a standard Knudsen diffusion cell with a flux ratio of $\sim 1:10$, while the substrate was maintained at 500 K during the growth process. After growth, the sample was transferred to STM chambers for STM/STS measurements. STS measurements were performed at 4.2 K by using a lock-in technique with a 20 mV_{rms} sinusoidal modulation at a frequency of 987.5 Hz. dI/dV spectra on a Au(111) substrate were used as an STS reference for tip calibration.

4.2 Theoretical calculation details

First-principles calculations were performed within the Vienna *ab initio* simulation package (VASP) [33], version 5.4.1, using the projector augmented-wave (PAW) method [34]. A plane-wave basis set was used,

with a kinetic energy cutoff of 420 eV. Electron exchange and correlation effects were treated using the generalized gradient approximation (GGA) functional of PBE [35]. PdSe₂ bilayers were modeled using a periodic 1×1 slab geometry with a vacuum thickness of 15 Å. All the atoms were allowed to relax along the calculated forces of less than $0.01 \text{ eV} \cdot \text{Å}^{-1}$. A $21 \times 21 \times 1$ Monkhorst-Pack [36] *k*-point mesh was used to sample the Brillouin zone. The simulated STM images were generated using the Tersoff-Hamann approximation [37].

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